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## (54) Mask design for forming tapered inkjet nozzles

Maskenmuster für die Herstellung von konische Tintenstrahldüsen Motif de masque pour la réalisation de buses à jet d'encre coniques

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#### Descripti n

The present invention generally relates to inkjet printers and, more particularly, to the formation of nozzles in a nozzle member for use with an inkjet printer.

Thermal inkjet printers operate by rapidly heating a small volume of ink and causing the ink to vaporize, thereby ejecting a droplet of ink through an orifice to strike a recording medium, such as a sheet of paper. When a number of orifices are arranged in a pattern, the properly sequenced ejection of ink from each orifice causes characters or other images to be printed upon the paper as the printhead is moved relative to the paper.

In these printers, print quality depends upon the physical characteristics of the orifices, or nozzles, in the printhead. For example, the geometry of the nozzles affects the size, shape, trajectory, and speed of the ink drop ejected.

Fig. 1 is a cross-section of a desirable type of thermal inkjet printhead 8. Printhead 8 includes a nozzle member 10, having a tapered nozzle 12. Affixed to a back surface of nozzle member 10 is a barrier layer 14, which channels liquid ink into a vaporization chamber 16. Liquid ink within vaporization chamber 16 is vaporized by the energization of a thin film resistor 18 formed on the surface of a semiconductor substrate 20, which causes a droplet of ink 22 to be ejected from nozzle 12.

Preferably, nozzle member 10 is formed of a polymer material, and nozzle 12 is formed in nozzle member 10 using laser ablation. Nozzle member 10 can also be formed of a photoresist material, where nozzle 12 is formed using photolithographic techniques or other techniques.

Tapered nozzles have many advantages over straight-bore nozzles. A tapered nozzle increases the velocity of an ejected ink droplet. Also, the wider bottom opening in the nozzle member 10 allows for a greater alignment tolerance between the nozzle member 10 and the thin film resistor 18, without affecting the quality of print. Additionally, a finer ink droplet is ejected, enabling more precise printing. Other advantages exist.

If nozzle 12 is to be formed using a laser, a tapered nozzle 12 may be formed by changing the angle of nozzle member 10 with respect to a masked laser beam during the orifice forming process. Another technique may be to use two or more masks for forming a single array of nozzles 12 where each mask would have a pattern corresponding to a different nozzle diameter. Still another technique is to defocus the laser beam during the orifice forming process. European Patent Application 367,541 by Canon describes such a defocusing technique and other techniques for forming tapered nozzles using a laser. U.S. Patent No. 4,940,881 to Sheets describes still another technique for forming tapered nozzles with a laser by rotating and tilting an optical element between the laser and the nozzle plate. These various techniques are considered time consuming, complicated, and subject to error.

Fig. 2 illustrates a conv ntional mask portion 24 having an opening 26 corresponding to where a nozzle is to be formed in a nozzle member. The opaque portion 28 of the mask is shown as being shaded. These conventional masks have been used in the past, in conjunction with various laser exposure techniques, for forming straight and single-angled tapered nozzles by controlling the fluence (mj/cm²) of laser radiation at the target substrate.

U.S. Patent No. 4,558,333 to Sugitani et al. describes a photolithographic process using a single mask to form tapered nozzles in a photoresist. The tapering is due to the opaque portions of the mask causing frustum shaped shadows through the photoresist layer corresponding to where nozzles are to be formed. After developing and etching the photoresist, the resulting nozzles have a frustum shape. The mask used is similar to that of Fig. 2 but where the opaque portion 28 and clear portion 26 are reversed.

This relatively simple method for forming tapered nozzles in photoresist nozzle members, using a single conventional mask, cannot be used for forming tapered nozzles in a polymer nozzle member using laser ablation.

EP-A-0264255 relates to the manufacture of ophthalmic lenses by means of an excimer laser. Ophthalmic lenses are fabricated by using a laser to cut, surface-model and bevel a workpiece which is preferably made of PMMA or of other plastics or glass. Figure 4 shows how the surface of the lens is modelled. The lens is placed into the part of an excimer laser beam which has a uniform energy distribution across its area and a mask is interposed between the workpiece and the beam. The mask has different degrees of transparency at different points on the mask. The mask may have a coating of variable transmission characteristics or it may be a neutral density filter with non-uniform transmission characteristics. However, the mask transmits a large amount of beam energy in the areas and a small amount in the areas, namely over the entire surface of the mask some degree of energy is transmitted through the mask towards the lens. Another embodiment uses a mask which is in the form of a semi-transparent mirror with a reflective coating whose thickness varies along its surface. In this case, the laser energy not used for ablation is reflected away from the workpiece. In other words, this document is directed to a mask which is used to form opthalmic lenses, wherein the mask does not have completely opaque portions distributed on it but simply has a coating with variable transmission characteristics or a filter having non-uniform transmission characteristics. The laser source and the transmission characteristics of the mask are specifically designed to produce a lens and not a nozzle.

Starting from this prior art, it is the object of the present invention to provide an apparatus and a method for forming one or more tapered nozzles in a nozzle

member for a print head which are highly reliable and enable the formation of the nozzles in a polymer nozzle member using laser ablation.

This object is achieved by an apparatus according to claim 1 and by a method according to claim 9.

### BRIEF DESCRIPTION OF THE DRAWINGS

Fig. 1 is a cross-section of a printhead for a thermal inkjet printer incorporating a nozzle member having tapered nozzles.

Fig. 2 is a conventional mask which has been previously used to form tapered nozzles in a nozzle member.

Fig. 3a and 3b illustrate one embodiment of a mask in accordance with the invention incorporating variable densities of opaque dots for forming tapered nozzles in a polymer nozzle member using laser ablation.

Fig. 4 illustrates a system for exposing a nozzle member material to masked radiation to form tapered nozzles

Fig. 5a is a perspective view of a tapered nozzle formed in a nozzle member using any of the masks shown in Figs. 3a-8b.

Fig. 5b is a cross-section of the nozzle member of Fig. 5a along line A-A illustrating the geometry of the 25 tapered nozzle.

Figs. 6a and 6b illustrate a second embodiment of a mask in accordance with the invention incorporating concentric, opaque rings, each having a same width, for forming a tapered nozzle in a polymer nozzle member using laser ablation.

Figs. 7a and 7b illustrate a third embodiment of a mask in accordance with the invention incorporating concentric, opaque rings having different widths for forming tapered nozzles in a polymer nozzle member using laser ablation.

Figs. 8a and 8b illustrate a fourth embodiment of a mask in accordance with the invention incorporating mask openings having a ruffled-shaped perimeter for forming tapered nozzles in a polymer nozzle number using laser ablation.

# <u>DETAILED DESCRIPTION OF THE PREFERRED</u> <u>EMBODIMENTS</u>

Fig. 3a is a top view of a portion of a mask 30 which may be used to form a tapered nozzle in a polymer nozzle member using laser ablation. Fig. 3b is a cross-section along line A-A in Fig. 3a.

In a preferred embodiment, mask 30 comprises a clear quartz substrate 32 with a thin layer of opaque material 34 formed over it where it is desired to block or reflect laser light. Opaque material 34 may be a layer of chrome, a UV enhanced coating, or any other suitable reflective or otherwise opaque coating. The type of laser which is preferred for use with the mask of Fig. 3a is an excimer laser.

A circular opening 35 in opaque material 34 defines

a single nozzle to be formed in a nozzle member.

Opaque dots 36 are distributed within circular pening 35 of mask 30. The distribution of these dots 36 effectively provides variable degrees of shading of the underlying nozzle member from the laser light. The arrangement of mask 30 with respect to a radiation source and a nozzle member is illustrated in Fig. 4, which will be discussed later.

The area of each of dots 36 may be the same or may be variable. The area of a dot 36 should be small enough to not be individually resolved on the underlying nozzle member. Dots 36 may have any shape, such as a circle, a square, or a thin line, and may be formed by conventional photolithographic techniques used to form masks. The desired mask pattern is dependent upon the optical resolution of the system at the specific operating wavelength. For example, for an excimer laser system emitting laser light having a wavelength of 2480 angstroms and a projection lens resolution of 2.0 microns, dots 36 preferable each have a maximum cross-section (i.e., width, diameter, etc.) of approximately 2.5 microns so as to not be individually resolved on the target substrate.

A higher density of dots 36 is shown around the periphery of the circular opening 35 in mask 30 to provide more shading around the periphery of a nozzle to achieve tapering of the nozzle. The arrangement of dots 36 will directly influence the shape of the nozzles in the nozzle member.

Fig. 4 illustrates an optical system 40, such as an excimer laser with beam shaping optics, directing a beam of radiation 42 onto a mask 44. Each opening 35 in mask 44 corresponds to opening 35 in Fig. 3a, where dots 36 are distributed as shown in Fig. 3a. Laser radiation 42 not blocked or reflected by any opaque portion passes through mask 44 and is transferred by lens system 45 to irradiate a polymer nozzle member 46. In a preferred embodiment, polymer nozzle member 46 comprises a material such as Kapton<sup>TM</sup>, Upilex<sup>TM</sup>, or their equivalent, and has a thickness of approximately 2 mils.

In a preferred embodiment, the material used for nozzle member 46 is provided on a reel, and this nozzle member material is unreeled from the reel and positioned under the image delivery system comprising mask 44 and lens system 45. The laser within the optical system 40 is then repetitively pulsed for a predetermined amount of time to ablate the nozzle member 46. The length of time the laser is energized, and the distribution of dots 36 on the mask of Fig. 3a, determine the geometry of the resulting nozzle 48.

After this ablation step, the nozzle member material is then stepped to a next position, and a new portion of the nozzle member material is unreeled under the image delivery system for laser ablation.

Figs. 5a and 5b illustrate a portion of nozzle member 46 and show a single nozzle 48 formed using the mask of Fig. 3a. Many variations of nozzle shapes may

be formed using the general principles described above. The particular distribution of dots 36 in Fig. 3a has been selected to form a variable-slope, tapered nozzle 48 in polymer nozzle member 46. Fig. 5b shows a cross-section of the nozzle 48 across line A-A in Fig. 5a.

The distribution of dots 36 can also be used to form the two-slope tapering of the nozzle shown in Fig. 1, or can be used to form a single, straight slope tapering.

In the preferred method, an excimer laser is used as the radiation source in optical system 40. The laser beam is focused approximately on the nozzle member 46 surface or slightly below the surface and pulsed approximately 300-400 times at a rate of 125 Hz, or whatever is deemed adequate depending upon the energy of the laser and thickness of the nozzle member. A preferred laser energy level is approximately 230 mj for each pulse of laser energy.

In one embodiment, 300 nozzles per inch are formed in nozzle member 46, and each nozzle has an ink exit diameter of 52 microns and an ink entrance diameter of 90 microns.

Mask 30 in Fig. 3a may also be used to form a tapered nozzle in a nozzle member formed of a photoresist material using a photolithographic technique. In this photolithographic technique, nozzle member 46 in Fig. 4 would be a layer of Vacrel<sup>™</sup> or another photoresist material formed on a substrate. Optical system 40 would include an ultraviolet radiation source with beam shaping optics. Mask 44 in Fig. 4, similar to mask 30 shown in Fig. 3a, would then be interposed between the optical system 40, providing ultraviolet radiation 42, and the photoresist. The exposed portion of the photoresist may then be removed in a conventional developing and etching step. The magnitude of the radiation 42 impinging on the photoresist determines the depth of exposure and the depth of etching of the photoresist. Thus, the partial shading of the photoresist by dots 36 enables the photoresist to be etched so as to define tapered nozzles as shown in Figs. 5a and 5b.

The above description applies where a positive photoresist is used. If a negative photoresist is used, where the exposed portions of the photoresist are insoluble in a developing solution, then the opaque and clear portions of the mask 44 are reversed.

Accordingly, Figs. 5a and 5b illustrate either a polymer nozzle member 46 after laser ablation through mask 44 or a photoresist nozzle member 46 after exposure using mask 44, and after developing and etching.

A laser ablation process is preferred over a photolithographic/photoresist process since the photoresist processes do not provide a stable, uniform pattern over a large area or over a long period of time. The abovedescribed laser ablation process, by virtue of its threshold phenomena and use of pre-polymerized materials, produces highly predictable patterns dependent upon the incident energy per unit area (fluence).

Figs. 6a and 6b illustrate a second embodiment of a

mask 56 incorporating the concepts used in this invention, where mask opening 58 includes concentric opaque rings 60. Fig. 6b is a cross-section of the mask of Fig. 6a along line A-A. In this embodiment, each opaque ring 60 has a same width, but the density of concentric rings 60 decreases with distance from the perimeter of the mask opening 58. Preferably, the width of each of concentric ring 60 is chosen to be small enough so as to not be resolved on the surface of the nozzle member but to only effectively act as variable shading of the radiation energy impinging on the nozzle

The shading action of rings 60 in forming a tapered nozzle is similar to that of dots 36 in Fig. 3a.

The resulting nozzle may be virtually identical to that shown in Figs. 5a and 5b. As with the mask in Figs. 3a and 3b, the mask of Figs. 6a and 6b may be used to form tapered nozzles in a polymer nozzle member by laser ablation or in a photoresist nozzle member using well known photolithographic techniques.

Figs. 7a and 7b show a third embodiment of a mask 64, where mask opening 66 includes concentric rings 68 which vary in both density and width. Fig. 7b is a cross-section of the mask 64 of Fig. 7a along line A-A. The action of rings 68 in forming tapered nozzles is similar to that of dots 36 in Fig. 3a.

Figs. 8a and 8b illustrate yet another embodiment of a mask 70, where a mask opening 72 has ruffled edges 74 which are preferably of a fine pitch so as not to be directly reproduced in the nozzle member. Fig. 8b is a cross-section of the mask 70 along line A-A. The action of the ruffled edges 74 provides partial shading of the nozzle member from a radiation source to form tapered nozzles in a manner similar to the action of dots 36 in Fig. 3a.

Ruffled edges 74 may have virtually any geometry as long as the variable shading of the nozzle member is achieved.

A wide variety of nozzle shapes may be formed using the mask patterns shown in Figs. 3a, 6a, 7a, and 8a.

Accordingly, an improved mask pattern and method for forming tapered nozzles in a nozzle member of a polymer material, such as a polyamide, or a photoresist material have been described.

Many other mask patterns will become obvious to those skilled in the art after reading this disclosure. This disclosure is not intended to limit the possible opaque patterns or opaque coating materials on a mask which may be used to achieve the desired nozzle tapering. Additionally, if a nozzle member formed of a negative photoresist is to be used, the mask pattern will essentially be a negative of the mask patterns shown in Figs. 3a, 6a, 7a, and 8a, and the unexposed portions of the nozzle member will be soluble in a developing solution.

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#### Claims

 An apparatus for forming one or more tapered nozzles (48) in a nozzle member (46) for a printhead, said apparatus comprising:

a radiation source (40); and

a mask (30,56,64,70) positioned between said radiation source (40) and said nozzle member 10 (46),

characterized in that said mask (30,56,64,70) comprises:

a transparent mask substrate (32); and

an opaque layer (34) formed on said substrate (32), said opaque layer (34) defining at least one opening, each of said at least one opening (35,58,66,72) corresponding to one of said one or more tapered nozzles (48) to be formed in said nozzle member (46), each of said at least one opening having opaque portions (36.60.68.74) formed therein, each of said opaque portions being substantially completely opaque to radiation emitted by said radiation source (40), said opaque portions (36,60,68,74) being distributed and arranged from a center of each of said at least one opening (35,58,66,72) in an increasing density to a periphery of each of said at least one opening such that said radiation emitted by said radiation source (40) completely ablates through said nozzle member (46) when passing through the center of each of said at least one opening and is blocked by said opaque portions defining said at least one opening to thereby form said one or more tapered nozzles (48).

- The apparatus of Claim 1 wherein said opaque portions comprise separate solid regions (36), each having approximately a same area, wherein the number of said solid regions increase in density toward said periphery of said at least one opening.
- 3. The apparatus of Claim 1 wherein said opaque portions comprise separate solid regions (36), said solid regions having a variety of areas, wherein the total area of said solid regions increase in density toward said periphery of said at least one opening.
- The apparatus of Claim 1 wherein said opaque portions comprise concentric opaque rings (60,68) which increase in density toward said periphery of said at least one opening.

- The apparatus of Claim 4 wherein said concentric rings hav a variety of widths (68).
- The apparatus of Claim 1 wherein a periphery of said at least one opening is formed to have a rippled pattern (72), wherein said opaque portions extend toward a center of said at least one opening.
- 7. The apparatus of Claim 1 wherein a cross-section of each of said opaque portions (36,60,68,74) is approximately at or less than an optical resolution of a lens system to be used in conjunction with said mask so as not, to individually resolve said opaque portions on a target substrate.
- The apparatus of Claim 1 wherein a cross-section of each of said opaque portions (36,60,68,74) is less than approximately 3 microns.
- 9. A method for forming tapered nozzles (48) in a nozzle member (46) comprising the steps of:

interposing a mask (30,56,64,70) between a radiation source (40) and said nozzle member (46), said mask having nozzle defining portions (35,58,66,72) corresponding to where nozzles (48) are to be formed in said nozzle member; and

energizing said radiation source to cause emitted radiation to impinge upon said nozzle member through said mask; characterized in that said mask (30,56,64,70) comprises

a transparent mask substrate (32); and

an opaque layer (34) formed on said substrate (32), said opaque layer (34) defining at least one opening, each of said at least one opening (35,58,66,72) corresponding to one of said one or more tapered nozzles (48) to be formed in said nozzle member (46), each of said at least one opening having opaque portions (36,60,68,74) formed therein, each of said opaque portions being substantially completely opaque to radiation emitted by said radiation source (40), said opaque portions (36,60,68,74) being distributed and arranged from a center of each of said at least one opening (35,58,66,72) in an increasing density to a periphery of each of said at least one opening such that said radiation emitted by said radiation source (40) completely ablates through said nozzle member (46) when passing through the center of each of said at least one opening

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and is blocked by said opaque portions defining said at least one opening to thereby form said one or more tapered nozzles (48).

10. The method of Claim 9 wherein said nozzle defining portions (35,58,66,72) are openings in said mask and said opaque portions (36,60,68,74) increase in density from a center of each of said openings to a periphery of each of said openings.

#### Patentansprüche

 Eine Vorrichtung zum Bilden einer oder mehrerer zugespitzter Düsen (48) in einem Düsenbauglied (46) für einen Druckkopf, wobei die Vorrichtung folgende Merkmale aufweist:

eine Strahlungsquelle (40); und

eine Maske (30, 56, 64, 70), die zwischen der Strahlungsquelle (40) und dem Düsenbauglied (46) positioniert ist, dadurch gekennzeichnet, daß die Maske (30, 56, 64, 70) folgende Merkmale aufweist:

ein transparentes Maskensubstrat (32); und

eine undurchsichtige Schicht (34), die auf dem Substrat (32) gebildet ist, wobei die undurchsichtige Schicht (34) mindestens eine Öffnung definiert, wobei jede der mindestens einen Öffnung (35, 58, 66, 72) einer der einen oder mehreren zugespitzten Düsen (48) entspricht, die in dem Düsenbauglied (46) gebildet werden sollen, wobei jede der mindestens einen Öffnung undurchsichtige Abschnitte (36, 60, 68, 74) in sich gebildet aufweist, wobei jeder der undurchsichtigen Abschnitte im wesentlichen vollständig undurchsichtig gegenüber einer Strahlung ist, die durch die Strahlungsquelle (40) emittiert wird, wobei die undurchsichtigen Abschnitte (36, 60, 68, 74) von einer Mitte jeder der mindestens einen Öffnung (35, 58, 66, 72) in einer zunehmenden Dichte zu einem Umfang von jeder der mindestens einen 50 Öffnung verteilt und angeordnet sind, derart, daß die Strahlung, die durch die Strahlungsquelle (40) emittiert wird, vollständig durch das Düsenbauglied (46) ablatiert, wenn dieselbe durch die Mitte jeder der mindestens einen Öffnung hindurchläuft, und durch die undurchsichtigen Abschnitte blockiert wird, die die mindestens eine Öffnung definieren, um dadurch die eine oder mehreren zugespitzten Düsen (48) zu bilden.

- Die Vorrichtung gemäß Anspruch 1, bei der die undurchsichtigen Abschnitte getrennte, durchgehende Regionen (36) aufweisen, wobei jede derselben etwa eine gleiche Fläche aufweist, bei der die Anzahl der durchgehenden Regionen bezüglich der Dichte hin zu dem Umfang der mindestens einen Öffnung zunimmt.
- 3. Die Vorrichtung gemäß Anspruch 1, bei der die undurchsichtigen Abschnitte getrennte, durchgehende Regionen (36) aufweisen, wobei die durchgehenden Regionen eine Vielfalt von Flächen aufweisen, wobei die Gesamtfläche der durchgehenden Regionen bezüglich der Dichte hin zu dem Umfang der mindestens einen Öffnung zunimmt.
- 4. Die Vorrichtung gemäß Anspruch 1, bei der die undurchsichtigen Abschnitte konzentrische, undurchsichtige Ringe (60, 68) aufweisen, die bezüglich der Dichte hin zu dem Umfang der mindestens einen Öffnung zunehmen.
- Die Vorrichtung gemäß Anspruch 4, bei der die konzentrischen Ringe (30) eine Vielfalt von Breiten (68) aufweisen.
- Die Vorrichtung gemäß Anspruch 1, bei der ein Umfang der mindestens einen Öffnung gebildet ist, so daß derselbe eine gekräuselte Struktur (72) aufweist, bei der sich die undurchsichtigen Abschnitte hin zu einer Mitte der mindestens einen Öffnung erstrecken.
- 7. Die Vorrichtung gemäß Anspruch 1, bei der ein Querschnitt jedes der undurchsichtigen Abschnitte (36, 60, 68, 74) etwa bei oder kleiner als eine optische Auflösung eines Linsensystems ist, das in Verbindung mit der Maske verwendet werden soll, um nicht die undurchsichtigen Abschnitte auf einem Zielsubstrat einzeln aufzulösen.
- Die Vorrichtung gemäß Anspruch 1, bei der ein Querschnitt jedes der undurchsichtigen Abschnitte (36, 60, 68, 74) kleiner als etwa 3 µm ist.
- 9. Ein Verfahren zum Bilden von zugespitzten Düsen (48) in einem Düsenbauglied (46), mit folgenden Schritten:

Positionieren einer Maske (30, 56, 64, 70) zwischen einer Strahlungsquelle (40) und dem Düsenbauglied (46), wobei die Maske düsendefinierende Abschnitte (35, 58, 66, 72) aufweist, die dem Ort entsprechen, an dem Düsen

(48) in dem Düsenbauglied gebildet werden sollen; und

Erregen der Strahlungsquelle, um zu bewirken, daß die emittierte Strahlung auf das Düsenbauglied durch die Maske auftrifft; dadurch gekennzeichnet, daß die Maske (30, 56, 64, 70) folgende Merkmale aufweist:

ein transparentes Maskensubstrat (32); und

eine undurchsichtige Schicht (34), die auf dem Substrat (32) gebildet ist, wobei die 15 undurchsichtige Schicht (34) mindestens eine Öffnung definiert, wobei jede der mindestens einen Öffnung (35, 58, 66, 72) einer der einen oder mehreren zugespitzten Düsen (48) entspricht, die in dem Düsenbauglied (46) gebildet werden sollen, wobei jede der mindestens einen Öffnung undurchsichtige Abschnitte (36, 60, 68, 74) in sich gebildet aufweist, wobei jeder der undurchsichtigen Abschnitte im 25 wesentlichen vollständig undurchsichtig gegenüber einer Strahlung ist, die durch die Strahlungsquelle (40) emittiert wird. wobei die undurchsichtigen Abschnitte (36, 60, 68, 74) von einer Mitte von jeder der mindestens einen Öffnung (35, 58, 66, 72) in einer zunehmenden Dichte zu einem Umfang jeder der mindestens einen Öffnung verteilt und angeordnet sind, derart, daß die Strahlung, die durch die Strahlungsquelle (40) emittiert wird, vollständig durch das Düsenbauglied (46) ablatiert, wenn dieselbe durch die Mitte jeder der mindestens einen Öffnung läuft, und durch die undurchsichtigen Abschnitte blockiert wird, die die mindestens eine Öffnung definieren, um dadurch die eine oder mehreren zugespitzten Düsen (48) zu bilden.

10. Das Verfahren gemäß Anspruch 9, bei dem die düsendefinierenden Abschnitte (35, 58, 66, 72) Öffnungen in der Maske sind, und bei dem die undurchsichtigen Abschnitte (36, 60, 68, 74) bezüglich der Dichte von einer Mitte jeder der Öffnungen zu einem Umfang jeder der Öffnungen 50 zunehmen.

#### Revendications

 Appareil servant à former une ou plusieurs buses (48) à section décroissante dans un élément à buses (46) pour une tête d'impression, ledit appareil comprenant : une source de rayonnement (40) ; et un masque (30, 56, 64, 70) positionné entre ladite source de rayonnement (40) et ledit élément à buses (46), caractérisé en ce que ledit masque (30, 56, 64, 70) comprend :

un substrat de masque transparent (32) ; et

une couche opaque (34) formée sur ledit substrat (32), ladite couche opaque (34) définissant au moins une ouverture, chacune desdites au moins une ouverture (35, 58, 66, 72) correspondant à une desdites une ou plusieurs buses (48) à section décroissante qu'il s'agit de former dans ledit élément à buses (46) chacune desdites au moins une ouverture présentant des portions opaques (36, 60, 68, 74) qui y est formée, chacune desdites portions opaques étant à peu près complètement opaque au rayonnement émis par ladite source de rayonnement (40), lesdites portions opaques (36, 60, 68, 74) étant distribuées et agencées à partir d'un centre de chacune desdites au moins une ouverture (35, 58, 66, 72) avec une densité croissante jusqu'à la périphérie de chacune desdites au moins une ouverture, de manière que ledit rayonnement émis par ladite source de rayonnement (40) enlève toute la matière à travers ledit élément à buses (46) lorsqu'il passe par le centre de chacune desdites au moins une ouverture et est arrêté par lesdites portions opaques définissant ladite au moins une ouverture pour former ainsi lesdites une ou plusieurs buses (48) à section décroissante.

- 40 2. Appareil selon la revendication 1, dans lequel lesdites portions opaques comprennent des régions pleines séparées (36), chacune ayant approximativement la même surface, dans lequel le nombre desdites régions pleines croît en densité vers ladite périphérie de ladite au moins une ouverture.
  - 3. Appareil selon la revendication 1, dans lequel lesdites portions opaques comprennent des régions pleines (36) séparées, lesdites régions pleines possédant différentes surfaces, dans lequel la surface totale desdites régions pleines croît en densité vers ladite périphérie de ladite au moins une ouverture.
  - 4. Appareil selon la revendication 1, dans lequel lesdites portions opaques comprennent des anneaux opaques concentriques (60, 68) qui croissent en densité vers ladite périphérie de ladite au moins une ouverture.

- Appareil selon la revendication 4, dans lequel lesdits anneaux concentriques ont différentes largeurs (68).
- 6. Appareil selon la revendication 1, dans lequel une périphérie de ladit au moins une ouverture est conformée de façon à avoir un dessin nervuré (72), dans lequel lesdites portions opaques s'étendent vers un centre de ladite au moins une ouverture.
- 7. Appareil selon la revendication 1, dans lequel une section transversale de chacune desdites portions opaques (36, 60, 68, 74) est approximativement égale ou inférieure à la résolution optique d'un système de lentilles, qu'il s'agit d'utiliser en combinaison avec ledit masque, de manière à ne pas résoudre individuellement lesdites portions opaques sur un substrat cible.
- Appareil selon la revendication 1, dans lequel la 20 section transversale de chacune desdites portions opaques (36, 60, 68, 74) est inférieure à environ 3 microns.
- 9. Procédé pour former des buses (48) à section 25 décroissante dans un élément à buses (46) comprenant les phases consistant à :

interposer un masque (30, 56, 64, 70) entre une source de rayonnement (40) et ledit élément à buses (46), ledit masque possédant une buse qui définit des portions (35, 58, 66, 72) correspondant aux emplacements où les buses (48) doivent être formées dans ledit élément à buses ; et activer ladite source de rayonnement pour faire tomber le rayonnement émis sur ledit élément à buses à travers ledit masque ;

caractérisé en ce que ledit masque (30, 56, 64, 70) comprend :

un substrat de masque transparent (32) ; et

une couche opaque (34) formée sur ledit substrat (32), ladite couche opaque (34) définissant au moins une ouverture, chacune desdites au moins une ouverture (35, 58, 66, 72) correspondant à une desdites une ou plusieurs buses (48) à section décroissante qu'il s'agit de former dans 50 ledit élément à buses (46), chacune desdites au moins une ouverture présentant des portions opaques (36, 60, 68, 74) qui y sont formées, chacune desdites portions opaques étant à peu près complètement 55 opaque au rayonnement émis par ladite source de rayonnement (40), lesdites portions opaques (36, 60, 68, 74) étant distri-

buées et agencées à partir d'un centre de chacune desdites au moins une ouverture (35, 58, 66, 72) avec une densité croissante jusqu'à la périphérie de chacune desdites au moins une ouverture, de manière que ledit rayonnement émis par ladite source de rayonnement (40) enlève toute la matière à travers ledit élément à buses (46) lorsqu'il passe par le centre de chacune desdites au moins une ouverture et soit arrêté par lesdites portions opaques définissant ladite au moins une ouverture pour former ainsi ladite ou lesdites une ou plusieurs buses (48) à section décroissante.

10. Procédé selon la revendication 9, dans lequel lesdites portions (35, 58, 66, 72) définissant la buse sont des ouvertures situées dans ledit masque et lesdites portions opaques (36, 60, 68, 74) croissent en densité du centre de chacune desdites ouvertures jusqu'à la périphérie de chacune desdites ouvertures.















